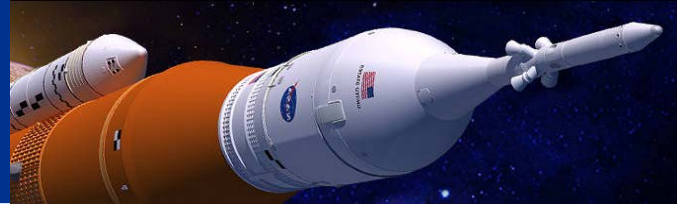


MIL-PRF-19500 Appendix J:

Inclusion of Plastic Encapsulated Discrete Semiconductor Devices for
Military Applications Task Group



Benny Damron

Jacobs Space Exploration Group

NASA Marshall Space Flight Center

Ronan Dillon, Microchip Ireland

Date 04-18-2019

JACOBS[®]

www.jacobs.com | worldwide

Agenda

1. Marshall Space Flight Center
2. Example MSFC Projects
3. MIL-PRF-19500 Task Appendix J Group Status
4. Differences in screening and qualification flows
5. Backup data

Marshall Space Flight Center (MSFC)



Charter: Space Launch, Propulsion,
Exploration Systems, Materials and
Manufacturing, Scientific Research

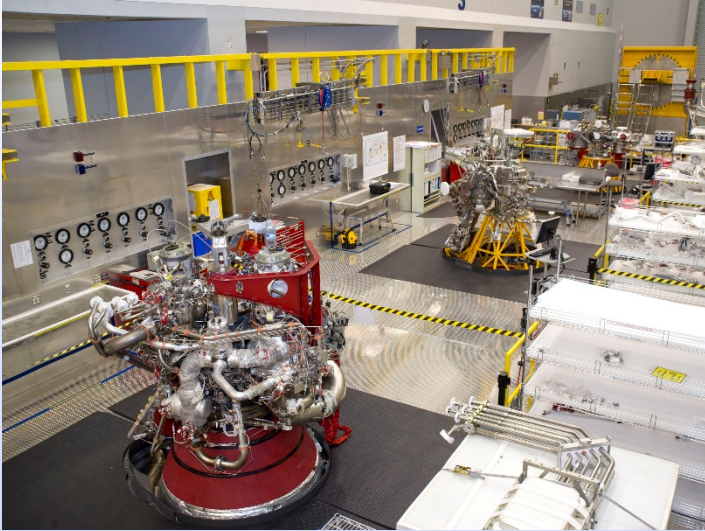
Photo courtesy of NASA



Life Sciences Glove Box for ISS

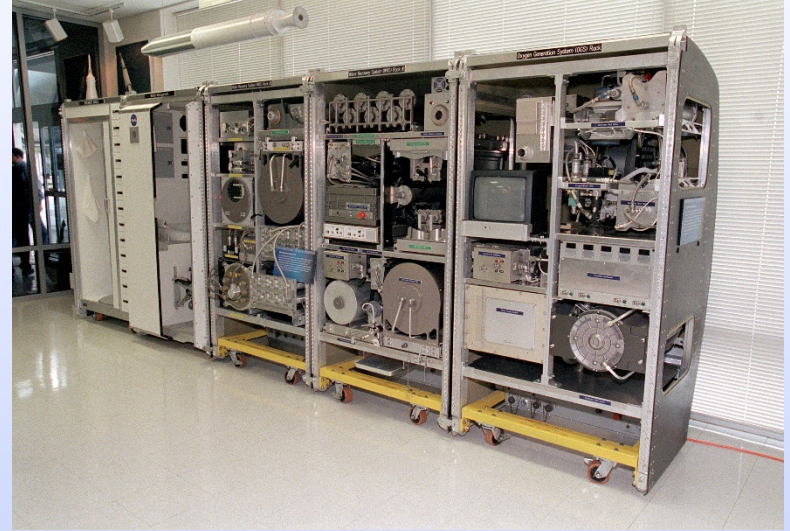
Photo courtesy of NASA

Marshall Space Flight Center (MSFC) Projects



SLS Main Engines

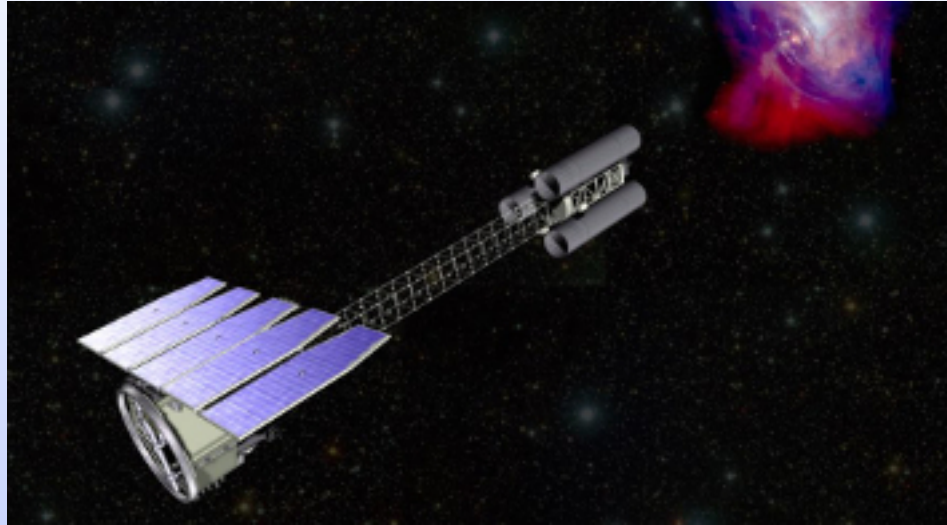
Photo courtesy of NASA



Environmental Controlled Life Support System
(ECLSS) used on ISS

Photo courtesy of NASA

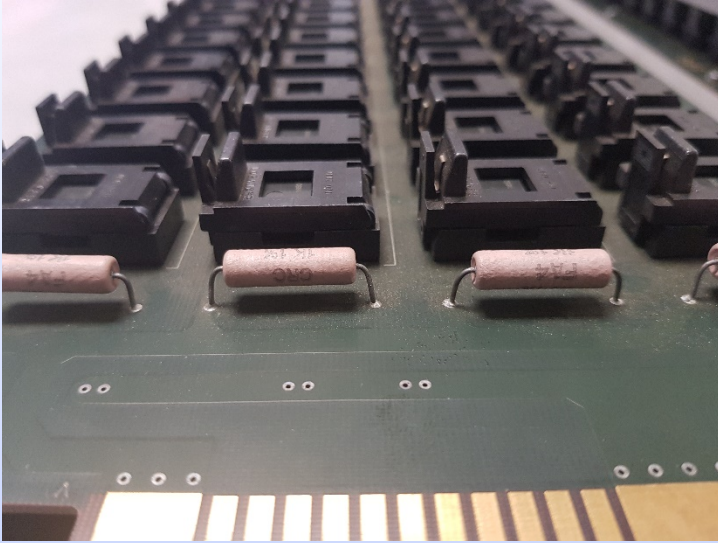
Marshall Space Flight Center (MSFC) Projects



Imaging X-Ray Polar Explorer (IXPE)

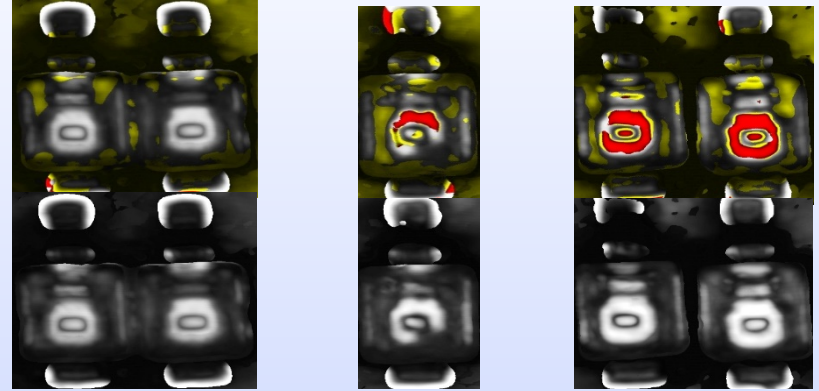
Photo courtesy of NASA

Microchip Technologies



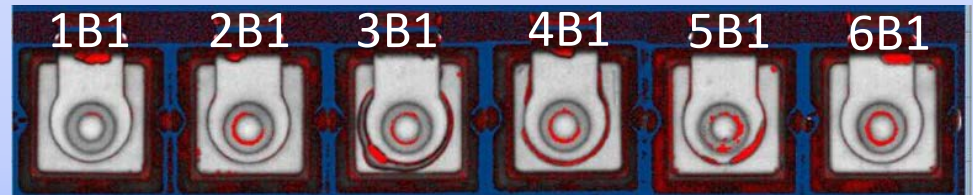
Burn-in board for plastic encapsulated discrete semiconductors

Photo courtesy of Microchip Technologies



Acoustic microscopy images of plastic encapsulated discrete semiconductors

Photos courtesy of Microchip Technologies



JACOBS[®]

19500 Appendix J Task Group

- Started to address need for military grade PEDs in government programs.
- Commercial PEDs
 - No control over changes
 - End of Life
 - Lower operating temperature range
 - Costly screening and qualification testing required for each lot
- Purpose: To develop a non-hermetic, non-cavity PED screening and qualification requirements for MIL-PRF-19500.
- Conducting teleconferences twice a month to keep document effort moving forward in between JEDEC meetings.

19500 Appendix J Task

- MIL-PRF-19500 Appendix J is not the same as the SAE AS6294/3 and AS6294/4 PEDS screening and qualification documents for commercial discrete semiconductors.
- Manufacturers will have to be qualified by Defense Logistics Agency (DLA) Land and Maritime in order to supply military qualified non-hermetic MIL-PRF-19500 devices to the government user community.
 - Periodic recertification audits by DLA are required.
- Initial DLA Land and Maritime device qualification will be for JANTXV-like and JANTX-like levels only. Part numbering scheme not defined yet.

19500 Appendix J Screening Differences

- Non-hermetic screening flow follows the hermetic screening with differences listed below and as shown in the following slides:
 - Temperature cycling is performed at a lower temperature range than hermetic devices.
 - High Temperature Reverse Bias performed at lower temperature of 125°C ambient temperature or 80 percent of maximum operating temperature if maximum temperature is less than 150°C.
 - Burn-in performed at lower temperature of 125°C junction temperature or 80 percent of maximum operating temperature if maximum temperature is less than 150°C.

19500 Appendix J Screening Differences Cont.'d

- Non-hermetic screening flow follows the hermetic screening with differences listed below and as shown in the following slides:
 - Radiography as specified.
 - 100 percent Acoustic Microscopy screening is required for non hermetic JANTXV and JANTX no hermeticity testing required

19500 Appendix J Screening Flow

	JANTXV/JANTX	JANTXV-like/JANTX-like
Screen	Hermetic	Non-hermetic
• Internal Visual	Yes	Yes
• High Temperature Non-operating life	Optional	Optional
• Temperature Cycling	Condition C*	Condition G**

* Method 1051 condition C temperature range is -55°C to +175°C

** Method 1051 condition G temperature range is -55°C to +150°C or maximum storage temperature.

19500 Appendix J Screening Flow Cont.'d

Screen	JANTXV/JANTX Hermetic	JANTXV-like/JANTX-like Non-hermetic
• Surge	Yes	Yes
• Thermal Impedance	Yes	Yes
• PIND	Optional	Not applicable

19500 Appendix J Screening Flow Cont.'d

Screen	JANTXV/JANTX Hermetic	JANTXV-like/JANTX-like Non-hermetic
• Interim Electrical Parameters	Yes	Yes
• High Temperature Reverse Bias	Yes	Yes*
• Interim Electrical Parameters	Yes	Yes

*Minimum T_j of 125°C or 80% of maximum operating temperature if less than 150°C

19500 Appendix J Screening Flow Cont.'d

	JANTXV/JANTX	JANTXV-like/JANTX-like
Screen	Hermetic	Non-hermetic
• Interim Electrical Parameters	Yes	Yes
• Burn in	Yes (Tj = 135°C typical)	Yes*

* Minimum Tj of 125°C or 80% of maximum operating temperature if less than 150°C.

19500 Appendix J Screening Flow Cont.'d

Screen	JANTXV/JANTX Hermetic	JANTXV-like/JANTX-like Non-hermetic
• Final Electrical Parameters	Yes	Yes
• Radiography	As specified	As specified
• Hermeticity	Yes	Not applicable
• Acoustic Microscopy	Not applicable	Yes

19500 Appendix J Screening Flow Cont.'d

Screen	JANTXV/JANTX Hermetic	JANTXV-like/JANTX-like Non-hermetic
• External Visual	No	Yes
• Case Isolation	As specified	Not applicable

19500 Appendix J Group A Qualification Differences

- Non-hermetic qualification flow = hermetic (except as noted)
 - Temperature cycling is performed at a lower temperature range than hermetic devices.
 - Added Autoclave or unbiased HAST option testing for small die flow
 - 100 percent Acoustic Microscopy screening is required for non hermetic JANTXV-like and JANTX

19500 Appendix J Group A Qualification Differences

- Group A subgroup 1, small die flow
 - Highly Accelerated Stress Testing
 - 130C/85% RH t = 96 hours, or
 - 110C/85% RH t = 264 hours, or
 - Autoclave – 121C/100% RH t = 96 hours
 - Temperature cycling test condition G instead of condition C

19500 Appendix J Group B Qualification Differences

- Non-hermetic qualification flow = hermetic (except as noted)
 - Temperature cycling is performed at a lower temperature range than hermetic devices.
 - Life testing (340 hours) performed at lower temperature (- 125°C or 80 percent of maximum operating temperature
 - Acoustic Microscopy screening is required as part of the decap design verification process.
 - Added Autoclave or unbiased HAST option testing for non small die flow products.
 - Added glass transition (Tg) temperature test.

19500 Appendix J Group B Qualification Differences

- Group B subgroup 2
 - Preconditioning per J-STD-020
 - Temperature cycling 500 cycles
- Group B subgroup 4
 - Acoustic Microscopy
 - Design verification using MIL-STD-750 test method 2075 and 1580 for plastic criteria
- Group B subgroup 7
 - Glass transition temperature T_g

19500 Appendix J Group C Qualification Differences

- Non-hermetic qualification flow = hermetic (except as noted)
 - Group C subgroup 2
 - Preconditioning per J-STD-020
 - Temperature cycling 500 cycles
 - Group C subgroup 3
 - Moisture sensitivity level
 - Highly Accelerated Stress Testing
 - Temperature cycling test condition G instead of condition C

19500 Appendix J Group E Qualification Differences

- Non-hermetic qualification flow = hermetic (except as noted)
 - Group E subgroup 1
 - Preconditioning per J-STD-020
 - High Temperature Storage life
 - HAST or Temperature Humidity Bias (THB)
 - Temperature cycling 700 cycles versus 500 for hermetic devices
 - Group E subgroup 9
 - Acoustic Microscopy
 - Moisture sensitivity level
 - Acoustic microscopy

19500 Appendix J Group E Qualification Differences

- Non-hermetic qualification flow = hermetic (except as noted)
 - Group E subgroup 10
 - Glassivation temperature - Tg
 - Plastic evaluation per MIL-STD-883 method 5011
 - Construction analysis per SAE AS6294/3 (pending release)
 - Outgassing and flammability per NASA-STD-6001

19500 Appendix J Task Group Future Plans

Current plan:

- Continue with the twice monthly teleconferences/webex meetings
- Develop a list of test methods for inclusion in MIL-STD-750

Future work:

- Goal is to have draft ready to turn over to JEDEC by May 2019 JEDEC task group meeting. DLA Land and Maritime will send the draft appendix J out as an EP Study prior to the May 2019 SAE/JEDEC meetings.

Thank You!!

We would like to express our gratitude to the NASA NEPAG and SLS programs, Government Working Group, and Microchip Technologies for their continued support of this effort.

Contact information:

Benny Damron
Jacobs Space Exploration Group (JSEG)
NASA Marshall Space Flight Center
Benny.Damron@nasa.gov

Ronan Dillon
Microchip Technologies
Ronan.Dillon@microchip.com

Back up Slides

19500 Appendix J Group A Qualification Differences

- Group A subgroup 1 small die flow

Temperature cycling (air to air) <u>4</u> /	1051	Test condition G, or maximum storage temperature, whichever is less, 25 cycles. 22 devices, c = 0
Autoclave or, UHASt or, UHASt		121C/100%RH t = 96 hrs, or 130C/85% RH t = 96 hrs, or 110C/85%RH t =264 hrs

19500 Appendix J Group B Qualification Differences

– Group B subgroup 2

<u>Subgroup 2</u>		
Preconditioning	JEDEC JESD2 2-A113	Test condition per JEDEC J-STD-020 Condition as specified and documented by supplier.
Temperature cycling (air-to-air)	1051	Test condition G, or maximum storage temperature, whichever is less. (500 cycles).
Electrical measurements		Group A, subgroup 2.

19500 Appendix J Group B Qualification Differences

– Group B subgroup 4

<u>Subgroup 4</u>		
Acoustic microscopy	J-STD-035	
Decap internal visual (design verification)	2075	Visual criteria in accordance with qualified design. Plastic concerns for 2075. Refer to MIL-STD-1580 Requirement 16 for plastic microcircuits,

19500 Appendix J Group B Qualification Differences

– Group B subgroup 7

Subgroup 7 Glass transition temperature	ASTM 1640	
--	--------------	--

19500 Appendix J Group C Qualification Differences

– Group C subgroup 2

<u>Subgroup 2</u>		
Preconditioning	JEDEC JESD2 2-A113	Test condition per JEDEC J-STD-020 Condition as specified and documented by supplier.
Temperature cycling (air-to-air)	1051	Test condition G, or maximum storage temperature, whichever is less. (500 cycles).
Electrical measurements		Group A, subgroup 2.

19500 Appendix J Group C Qualification Differences

– Group C subgroup 3

<u>Subgroup 3</u>		
Preconditioning	JEDEC JESD22- A113	Test condition per JEDEC J-STD-020 Condition as specified and documented by supplier.
Temp cycle Air to air	1051	Test condition G (-55C/+150C) , or maximum storage temperature, whichever is less. (100 cycles).
Highly Accelerated Stress Test (HAST, Biased) or Temp Humidity Bias	JEDEC JESD22- A110	130C/85%RH, biased, 96 hours or 110C/85%RH, biased, 264 hours or 85C/85%RH, biased, 1000 hours
Electrical measurements		Group A, subgroup 2.

19500 Appendix J Group E Qualification Differences

- Group E subgroup 9

<u>Subgroup 9</u>			
Acoustic Microscopy	JEDEC J-STD-035	Delamination >10%	10 devices from MSL sample. C = 0
Moisture Sensitivity Level Classification	JEDEC J-STD-020	Test is performed to determine moisture sensitivity level per JEDEC J-STD-020. Conditions will be used based on supplier data available. Moisture level will be the lowest numerical level (1-6) that has no failures based on pass/fail criteria in J-STD-020.	45 devices, c = 0
Acoustic Microscopy <u>3/</u>	JEDEC J-STD-035	Delamination >10%, no additional delamination from pre-stress.	10 devices from previous Acoustic Microscopy C = 0
Electrical Measurements		Group A, subgroup 2.	45 devices, c = 0

19500 Appendix J Group E Qualification Differences

- Group E subgroup 10

Subgroup 10		
Glassivation Temperature (Tg)	ASTM E1640	
Plastic evaluation	883/50 11	Type I electrically conductive or Type II electrically insulative
Construction analysis	SAE62 94/3	A construction analysis as per SAE6294/3 (pending release) is recommended
Outgassing	ASTM E595	